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APPLICATION NO.	FI	LING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/619,039	07/14/2003		Yasushi Koubuchi	501.36127CC3	6056
20457	7590	06/14/2006		EXAM	INER
ANTONEL	LI, TERI	RY, STOUT & KI	PHAM, LONG		
1300 NORTH SEVENTEENTH STREET SUITE 1800 ARLINGTON, VA 22209-3873				ART UNIT	PAPER NUMBER
				2814	

DATE MAILED: 06/14/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
	10/619,039	KOUBUCHI ET AL.	
Office Action Summary	Examiner	Art Unit	
	Long Pham	2814	
The MAILING DATE of this communication Period for Reply	appears on the cover sheet w	ith the correspondence address	
A SHORTENED STATUTORY PERIOD FOR RE WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory pe - Failure to reply within the set or extended period for reply will, by st Any reply received by the Office later than three months after the m earned patent term adjustment. See 37 CFR 1.704(b).	G DATE OF THIS COMMUNI R 1.136(a). In no event, however, may a . riod will apply and will expire SIX (6) MOI atute, cause the application to become A	CATION. reply be timely filed NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).	
Status			
1) Responsive to communication(s) filed on 0	<u> 4 April 2006</u> .		
2a)⊠ This action is FINAL . 2b)□ 1	This action is non-final.		
3) Since this application is in condition for allo	·		
closed in accordance with the practice unde	er <i>Ex parte Quayle</i> , 1935 C.[D. 11, 453 O.G. 213.	
Disposition of Claims			
4)⊠ Claim(s) <u>11-17</u> is/are pending in the applica	ation.		
4a) Of the above claim(s) is/are without	drawn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>11-17</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction an	d/or election requirement.		
Application Papers			
9) The specification is objected to by the Exam	niner.		
10) The drawing(s) filed on is/are: a)	accepted or b) objected to	by the Examiner.	
Applicant may not request that any objection to	the drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the cor	rection is required if the drawing	g(s) is objected to. See 37 CFR 1.121(d)	
11)☐ The oath or declaration is objected to by the	Examiner. Note the attache	d Office Action or form PTO-152.	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for fore	eign priority under 35 U.S.C.	§ 119(a)-(d) or (f).	
a) ☐ All b) ☐ Some * c) ☐ None of:			
1. Certified copies of the priority docum	ents have been received.		
2. Certified copies of the priority docum	ents have been received in A	Application No	
3. Copies of the certified copies of the p	priority documents have beer	received in this National Stage	
application from the International Bur			
* See the attached detailed Office action for a	list of the certified copies not	received.	
Attachment(s)			
Attachment(s) 1) Notice of References Cited (PTO-892)	4) ☐ Interview	Summary (PTO-413)	

2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date <u>04/05/06</u>.

6) Other: __

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DETAILED ACTION

Rejections and/or objections necessitated by the amendments *Claim Rejections - 35 USC § 103**

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 11, 13, 15, and 17 as currently amended, and 12 and 16 as previously presented, are rejected under 35 U.S.C. 103(a) as being unpatentable over Hirabayshi (US 5,614,445) in combination with Gocho et al. (US patent 5,498,565), and Taguchi (US patent 4,935,800).

With respect to claims 11, 12, 13, 15, 16, and 17, Hirabayshi in combination with Gocho et al. teach the invention as claimed. See the contents of the final rejection dated 07/14/05 and rejections dated 01/04/06.

Hirabayshi teaches forming dummy regions, the dummy regions would inherently have a number, a size, and a layout. Further, it is submitted that the how the surface of the element isolation insulating films are planarized has not been given patentable weight since claims are directed to a device or structure.

Claim Rejections - 35 USC § 103

Claim 14 as previously presented is rejected under 35 U.S.C. 103(a) as being unpatentable over Hirabayshi (US 5,614,445) in combination with Gocho et al. (US patent 5,498,565), and Taguchi (US patent 4,935,800).

See the rejections dated 07/14/05 and 01/04/06.

Response to Arguments

Applicant's arguments with respect to claims 11-17 have been considered but are most in view of the new ground(s) of rejection.

In response to the applicant's arguments on pages 6 and 7 of the amendment dated 04/04/06, it is submitted that a prior art reference is evaluated by what it suggests to one versed in the art, rather than by its specific disclosure.

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In re Bozek, 163 USPQ 545 (CCPA 1969). Further, it is submitted that a reference is considered not only for what it expressly states, but for what it would reasonbly have suggested to one of ordinary skill in the art. In re DeLisle, 160 USPQ (CCPA 1969). In this particular case, Hirabayshi teaches a semiconductor device comprising of:

trenches 4',6' formed in a substrate 1,2 and defining active regions 17 and dummy regions 5; and

element isolation insulating films 8,8a buried in said trenches to serve as element isolation regions, wherein said dummy regions are formed at a scribing area 5 and wherein the length of one of the dummy regions is shorter than a distance between external terminals 17a,17b.

Further in response to the arguments in the first full paragraph on page 7 of the amendment dated 04/04/06, it is submitted that the limitation "... dummy regions filled completely with an insulating film or layer... " is not recited in present claims.

In response to the applicant's arguments on page 8 of the amendment dated 04/04/06, it is submitted that Gocho et al. is being relied on only for the teaching of trench isolation filled with planarized insulation to increase capacitance and minimize chip area. Further, it is submitted that the fact that the applicants have a different reason or advantage resulting from doing what the relied prior art suggested doing is not indicative or demonstrative of unobviousness. In Re Kronig 190 USPQ 425,428 (CCPA 1976); In Re Lintner 173 USPQ 560 (CCPA 1972).

In response to the applicant's arguments on pages 9 and 10 of the amendment dated 04/04/06, it is submitted that Taguchi broadly teaches a trench isolation having filled with dielectric to reduce parassitic capacitance. Further, it is noted that one of the definitions of "fill" is "to occupy the whole of". Further, it is submitted that a prior art reference is evaluated by what it suggests to one versed in the art, rather than by its specific disclosure. In re Bozek, 163 USPQ 545 (CCPA)

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1969). Further, it is submitted that a reference is considered not only for what it expressly states, but for what it would reasonbly have suggested to one of ordinary skill in the art. In re DeLisle, 160 USPQ (CCPA 1969). In this particular case, the broad teaching of filling trench isolation of Taguchi would be either partially filling or completely filling to one skilled in the art.

Conclusion

Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Long Pham whose telephone number is 571-272-1714. The examiner can normally be reached on Mon-Frid, 10am to 5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on 571-272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Long Pham
Primary Examiner
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